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	Subclass	
Class		ISSUE CLASSIFICATION

JC 92
JC 83a

PATENT NUMBER

6283131



6283131

U.S. UTILITY Patent Application

O.I.P.E.	PATENT DATE
SCANNED	10/30/2001

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/669159	NO	134	1.2	1763	Gouldream

APPlicants

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TITLE

1. Nitride process for polysilicon etching in deep submicron technology

PTO-2040
12/99

ISSUING CLASSIFICATION

1. Continued on Issue Slip Inside File Jacket

7-17-01 Formal Drawings (shts) set 1

9-25-60

TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
The term of this patent subsequent to _____ (date) has been disclaimed.	6	12	8	19	1
The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____	<u>George Goudreau</u> 5-01 <small>(Assistant Examiner)</small> <small>(Date)</small>			NOTICE OF ALLOWANCE MAILED 5-9-01	
	<u>GREGORY MILLS</u> <small>Primary Examiner</small> <small>TECHNOLOGY CENTER 1700</small> <small>(Primary Examiner)</small> <small>(Date)</small>			ISSUE FEE Amount Due <u>\$1240.00</u> Date Paid <u>6/29/01</u>	
The terminal _____ months of	<u>May - 1240</u>			ISSUE BATCH NUMBER	

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ISSUE FEE IN FILE

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